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**Jean-Emmanuel Broquin
Christoph M. Greiner**
Editors

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Contents

vii Conference Committee

WAVEGUIDE ENGINEERING

- 7218 02 **Chalcogenide films for infrared integrated optics (Invited Paper) [7218-01]**
C. Vigreux, A. Pradel, Institut Charles Gerhardt-Institut de Chimie Moléculaire et des Matériaux de Montpellier, CNRS, UMII, ENSCM, UMI, Univ. Montpellier II (France)
- 7218 03 **As₂S₃/Sr(Ti_{0.7}Co_{0.3})O₃ and As₂S₃/Sr(Ti_{0.6}Fe_{0.4})O₃ strip-loaded waveguides for integrated magneto-optical isolator applications [7218-02]**
L. Bi, H.-S. Kim, J. Hu, L. C. Kimerling, C. A. Ross, Massachusetts Institute of Technology (United States)
- 7218 04 **New practical approach of integrated photonic based on biomimetic peptidic/silica self-assembled nanotubes [7218-03]**
D. Duval, C. Tarabout, N. Huby, F. Artzner, Institute of Physics, CNRS, Univ. de Rennes I (France); E. Gaviot, Lab. of Acoustics, CNRS, Univ. of Le Mans (France); J. Zyss, IFR of ALEMBERT, CNRS, ENS Cachan (France); A. Renault, E. Pouget, B. Bêche, Institute of Physics, CNRS, Univ. de Rennes I (France)
- 7218 05 **980nm-1550nm vertically integrated duplexer for hybrid erbium-doped waveguide amplifiers on glass [7218-04]**
L. Onestas, T. Nappez, E. Ghibaudo, G. Vitrant, J.-E. Broquin, Institut de Microélectronique, Electromagnétisme et Photonique, LaHC, INP Grenoble (France)
- 7218 06 **Waveguide optical amplifier for telecom applications [7218-05]**
S. Taccheo, M. Zannin, K. Ennsner, Swansea Univ. (United Kingdom); D. Careglio, J. Solé-Pareta, Univ. Politècnica de Catalunya (Spain); J. Aracil, Univ. de Madrid (Spain)
- 7218 07 **Annealing effect on optical barrier in ion-implanted tellurite glass waveguides [7218-06]**
S. Berneschi, I. Cacciari, Nello Carrara Institute of Applied Physics (Italy); G. Nunzi Conti, Nello Carrara Institute of Applied Physics (Italy) and Ctr. Studi e Ricerche Enrico Fermi (Italy); S. Pelli, G. C. Righini, Nello Carrara Institute of Applied Physics (Italy); I. Bányász, Research Institute for Solid State Physics and Optics (Hungary); N. Q. Khanh, T. Lohner, P. Petrik, Z. Zolnai, Research Institute for Technical Physics and Materials Science (Hungary); M. Bettinelli, A. Speghini, Univ. degli Studi di Verona (Italy); L. Mescia, F. Prudenzeno, Politecnico di Bari (Italy)

GRATING COUPLERS

- 7218 08 **Interfacing optical fibers and high refractive index contrast waveguide circuits using diffractive grating couplers (Invited Paper)** [7218-07]
G. Roelkens, D. Taillaert, F. Van Laere, D. Vermeulen, J. Schrauwen, S. Scheerlinck, T. Claes, W. Bogaerts, P. Dumon, S. Selvaraja, D. Van Thourhout, R. Baets, Ghent Univ. (Belgium)
- 7218 09 **Compact silicon diffractive components for integrated optics** [7218-08]
Z. Zhou, Peking Univ. (China), Huazhong Univ. of Science and Technology (China), and Georgia Institute of Technology (United States); J. Feng, H. Yi, H. Wu, Huazhong Univ. of Science and Technology (China)
- 7218 0A **Efficient small grating couplers for low-index difference waveguide systems** [7218-09]
R. Bruck, R. Hainberger, Austrian Research Ctrs. GmbH (Austria)
- 7218 0B **Polymer wedge for perfectly vertical light coupling to silicon** [7218-10]
J. Schrauwen, S. Scheerlinck, D. Van Thourhout, R. Baets, Ghent Univ. (Belgium)

INTEGRATED DIFFRACTIVE PHOTONICS

- 7218 0C **Developments in arrayed waveguide grating devices for photonic integrated circuits (Invited Paper)** [7218-11]
X. Leijtens, M. Smit, Technische Univ. Eindhoven (Netherlands)
- 7218 0E **Spiral planar-waveguide Bragg gratings** [7218-13]
C. Lin, E. W. Jacobs, J. S. Rodgers, SPAWAR Systems Ctr. (United States)
- 7218 0F **Tunable spectral slicing filter utilizing sparse grating in Ti:LiNbO₃** [7218-14]
R. C. Rabelo, Instituto de Estudos Avançados (Brazil); O. Eknayan, H. F. Taylor, Texas A&M Univ. (United States)

MODELING AND DESIGN

- 7218 0G **Linear and nonlinear modeling of light propagation in hollow-core photonic crystal fiber (Invited Paper)** [7218-15]
P. J. Roberts, J. Laegsgaard, Danish Technical Univ. (Denmark)
- 7218 0H **A unified theory for surface emitting chirped circular grating lasers** [7218-16]
X. Sun, A. Yariv, California Institute of Technology (United States)
- 7218 0J **Analysis of surface plasmon resonance with Goos-Hanchen shift using FDTD method** [7218-18]
G.-Y. Oh, Chung-Ang Univ. (Korea, Republic of); D.-G. Kim, Korea Photonics Technology Institute (Korea, Republic of); H.-S. Kim, Y.-W. Choi, Chung-Ang Univ. (Korea, Republic of)
- 7218 0K **Impedance mismatch approach for a near-field superlens with intrinsic loss of absorption** [7218-19]
K. Lee, K. Kim, Yonsei Univ. (Korea, Republic of)

- 7218 0L **Generation of M-ary signals using a single Mach Zehnder interferometer** [7218-20]
Y. Ehrlichman, O. Amrani, S. Ruschin, Tel Aviv Univ. (Israel)

PHOTONIC INTEGRATION

- 7218 0N **Backscatter in integrated optical waveguides and circuits** [7218-22]
A. Canciamilla, M. Torreggiani, C. Ferrari, Politecnico di Milano (Italy); F. Morichetti, Politecnico di Milano (Italy) and CoreCom (Italy); R. Costa, CoreCom (Italy); A. Melloni, Politecnico di Milano (Italy)
- 7218 0O **Integration of InP-based optoelectronics with silicon waveguides (Invited Paper)** [7218-23]
T. Aalto, M. Harjanne, M. Kapulainen, S. Ylinen, J. Ollila, VTT Technical Research Ctr. of Finland (Finland); V. Vilokinen, Modulight, Inc. (Finland); L. Mörl, M. Möhrle, Fraunhofer HHI (Germany); R. Hamelin, Intexys Photonics (France)
- 7218 0P **Wafer-level optics enables low cost camera phones** [7218-24]
Y. Dagan, Tessera, Inc. (United States)
- 7218 0Q **Near-field nano-imaging by nanophotodetector array** [7218-25]
B. Liu, K. Y. Kim, Y. Huang, S.-T. Ho, Northwestern Univ. (United States)

PLASMONICS II

- 7218 0W **Guidewave surface plasmon-polariton sensors (Invited Paper)** [7218-31]
R. Kashyap, G. Nemova, École Polytechnique de Montréal (Canada)
- 7218 0X **Surface plasmon based real-time microfluid temperature sensor** [7218-32]
L. J. Davis III, M. Deutsch, Univ. of Oregon (United States)
- 7218 0Y **Large enhancement of second-harmonic generation in subwavelength metal-dielectric-metal plasmonic waveguides** [7218-33]
G. Veronis, Louisiana State Univ. (United States); S. Fan, Stanford Univ. (United States)

SENSING I

- 7218 14 **Ultracompact fully integrated megapixel multispectral imager (Invited Paper)** [7218-40]
J. M. Eichenholz, Ocean Optics, Inc. (United States); J. Dougherty, Ocean Thin Films (United States)
- 7218 15 **Active resonant subwavelength grating devices for high speed spectroscopic sensing** [7218-41]
A. V. Gin, S. A. Kemme, R. R. Boye, D. W. Peters, J. F. Ihlefeld, R. D. Briggs, J. R. Wendt, L. H. Marshall, Sandia National Labs. (United States); T. R. Carter, Sandia Staffing Alliance, LLC (United States); S. Samora, LMATA Government Services LLC (United States)

- 7218 16 **Multi-aperture Fourier spectrometers in planar waveguides** [7218-42]
M. Florjańczyk, York Univ. (Canada) and National Research Council Canada (Canada);
P. Cheben, S. Janz, B. Lamontagne, J. Lapointe, National Research Council Canada
(Canada); A. Scott, York Univ. (Canada) and COM DEV Ltd. (Canada); K. Sinclair,
B. Solheim, York Univ. (Canada); D.-X. Xu, National Research Council Canada (Canada)
- 7218 17 **Development of a ion-exchanged glass integrated optics DFB laser for a LIDAR application**
[7218-43]
L. Bastard, J.-E. Broquin, IMEP-LaHC Institute (France); F. Gardillou, C. Cassagnettes, Teem
Photonics S.A. (France); J.-P. Schlotterbeck, P. Rondeau, Thalès Avionics S.A. (France)
- 7218 18 **Refractive-index sensor incorporating a polymeric waveguide overlaid with TiO₂ thin films**
[7218-44]
G.-S. Son, Kwangwoon Univ. (Korea, Republic of); S.-W. Kwon, Sungkyunkwan Univ. (Korea,
Republic of); W.-K. Kim, W.-S. Yang, H.-M. Lee, H.-Y. Lee, Korea Electronics Technology
Institute (Korea, Republic of); S.-D. Lee, Infopia Co., Ltd. (Korea, Republic of); S.-S. Lee,
Kwangwoon Univ. (Korea, Republic of)

SENSING II

- 7218 1A **Wavelength interrogation of optical waveguide biosensors in the input grating coupler
configuration** [7218-46]
S. Grego, B. R. Stoner, RTI International (United States)
- 7218 1B **Integrated acousto-optic polarization analyzer sensor** [7218-47]
L. Poffo, A2 PHOTONIC SENSORS (France); P. Lemaître-Auger, LCIS, INPG (France);
P. Benech, P. Benech, IMEP - LHAC (France)
- 7218 1C **Analysis of hydrogen exposure effects on the transmittance of periodic sub-wavelength
palladium hole arrays** [7218-48]
E. Maeda, K. Endo, S. Mikuriya, M. Shuzo, I. Yamada, J.-J. Delaunay, The Univ. of Tokyo
(Japan)

POSTER SESSION

- 7218 1E **New type of standalone gas sensors based on dye thin films and subwavelength structures**
[7218-50]
M. Schnieper, L. Davoine, Ctr. Suisse d'Electronique et de Microtechnique SA Basel Ctr.
(Switzerland); M. Holgado, R. Casquel del Campo, Univ. Politécnica de Madrid (Spain);
A. Barranco, Consejo Superior de Investigaciones Científicas (Spain)
- 7218 1F **Path folding and path shifting system at 1550 nm using multiple Bragg holographic gratings**
[7218-51]
A.-H. Phan, N. Kim, J.-H. Park, Chungbuk National Univ. (Korea, Republic of); K.-Y. Lee,
Suncheon National Univ. (Korea, Republic of)

Author Index

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and Centro Studi e Ricerche Enrico Fermi (Italy)

Frank Schmidt, Zuse Institut Berlin (Germany)

Session Chairs

- 1 Waveguide Engineering
Jean-Emmanuel Broquin, Institut de Microélectronique
Électromagnétisme Photonique, Laboratoire d'Hyperfréquence et
Caractérisation (France)
- 2 Grating Couplers
Christoph M. Greiner, LightSmyth Technologies, Inc. (United States)
- 3 Integrated Diffractive Photonics
Pavel Cheben, National Research Council Canada (Canada)
- 4 Modeling and Design
Yakov Sidorin, Bromberg Sunstein LLP (United States)
- 5 Photonic Integration
Andrea Melloni, Politecnico di Milano (Italy)
- 6 Plasmonics I
Pierre Berini, University of Ottawa (Canada)
- 7 Plasmonics II
Robert L. Nelson, Air Force Research Laboratory (United States)
- 8 Micro Resonators
Gualtiero Nunzi Conti, Istituto di Fisica Applicata Nello Carrara (Italy)
and Centro Studi e Ricerche Enrico Fermi (Italy)
- 9 Sensing I
Andrea Melloni, Politecnico di Milano (Italy)
- 10 Sensing II
Xudong Fan, University of Missouri, Columbia (United States)